

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	substrate and (dielectric Silicon near oxide SiO) and semiconductor near nano-crystal and laser near irradiat\$3	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2005/08/25 12:19
L2	1	(substrate and (dielectric Silicon near oxide SiO) and semiconductor near nano-crystal and laser near irradiat\$3).CLM.	US-PGPUB; USPAT; USOCR; EPO; JPO	OR	OFF	2005/08/25 12:20